AMENDMENT UNDER 37 C.F.R. § 1.111

U.S. Application No.: 09/885,943

both the amorphous layer and the crystalline layer being made of boron phosphide (BP),

the gallium nitride phosphide single crystal layer consisting of GaN<sub>0.97</sub>P<sub>0.03</sub> is formed in

contact with the crystalline layer of boron phosphide, and

a light-emitting layer made of cubic  $Ga_{0.94}In_{0.06}N$  is formed on said gallium nitride

phosphide single crystal layer consisting of  $GaN_{0.97}P_{0.03}$ .

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